

## Abstract

Different thin films samples made of SnO<sub>2</sub>, F:SnO<sub>2</sub>, Pd: SnO<sub>2</sub> and and co-doped Pd-F: SnO<sub>2</sub> were deposited at a substrate temperature of 450oC using optimized doping concentrations of F and Pd, thereafter the samples were annealed and passivated in a tube furnace at 450oC. Optical and electrical methods were used in characterizing the thin film samples: The band gap energy for all samples was extracted from optical data using a proprietary software, Scout™ 98. The calculated band gap energy were found to be 4.1135eV for Pd:SnO<sub>2</sub> and 3.8014eV for F:SnO<sub>2</sub> being the highest and the lowest calculated band gap energies, respectively. The wide band gap energy has been attributed to the incorporation of Pd ions in crystal lattice of SnO<sub>2</sub> thin film for Pd:SnO<sub>2</sub> while for F:SnO<sub>2</sub> has been due to incorporation of F- ions in the crystal lattice of SnO<sub>2</sub> which gives rise to donor levels in the SnO<sub>2</sub> band gap. This causes the conduction band to lengthen resulting to a reduction in the band gap energy value. The electrical resistivity was done by measuring the sheet resistance of the SnO<sub>2</sub>, Pd:SnO<sub>2</sub>, F:SnO<sub>2</sub> and Pd-F:SnO<sub>2</sub> thin films. The undoped SnO<sub>2</sub> thin film had the highest sheet resistivity of 0.5992 Ωcm while F:SnO<sub>2</sub> had the lowest sheet resistivity of 0.0075 Ωcm. The low resistivity of F:SnO<sub>2</sub> results from substitution incorporation of F- ions in the crystal lattice of SnO<sub>2</sub> thin films, instead of O- ions which lead to an increase in free carrier concentration. The Pd-F:SnO<sub>2</sub> gas sensor device was tested for CO<sub>2</sub> gas sensing ability using a lab assembled gas sensing unit. The performance of the gas sensor device was observed that: the as prepared device was more sensitive to CO<sub>2</sub> gas than those subjected to annealing and passivation. The decrease in the sensitivity of the annealed Pd-F: SnO<sub>2</sub> gas sensor is attributed to decrease in grain boundary potential resulting from grain growth. This causes a decrement in adsorption properties of CO- and O- species by the annealed Pd-F: SnO<sub>2</sub> thin film. The sensitivity of passivated Pd-F: SnO<sub>2</sub> gas sensor was found to be the lowest. The low sensitivity is due to the effects of nitration and decrement in grain boundary potential resulting from grain growth, nevertheless, the sensitivity of the passivated Pd-F: SnO<sub>2</sub> thin film was found to be within the range for gas sensing applications.